

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

<b>INFORMATION DISCLOSURE STATEMENT (PTO 1449)</b>		ATTORNEY DOCKET NO. <b>70020.0061USWO</b>	
		U.S. APPLICATION SERIAL NO. <b>10/533,223</b>	CONFIRMATION NO. <b>8884</b>
		FILING DATE <b>April 27, 2006</b>	
INVENTOR(S) <b>Yukio Nishimura et al</b>		EXAMINER <b>Amanda C. WALKER</b>	
TITLE OF APPLICATION <b>RADIATION-SENSITIVE RESIN COMPOSITION</b>		ART UNIT <b>1752</b>	

U.S. PATENT DOCUMENTS						
EXAMINER INITIAL		DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS
/ACW/	A	7,108,951	09/19/06	Tomoya Sasaki	430	270.1
/ACW/	B	2004/0175645 A1	09/09/04	Tomoya Sasaki	430	270.1

FOREIGN PATENT DOCUMENTS							
		DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO
/ACW/	C	EP1341038	09/03/03	Europe			

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)	
	D

EXAMINER  /Amanda C. Walke/	DATE CONSIDERED  02/19/2008
EXAMINER: Initial if the reference is considered, whether or not the citation is in conformance with MPEP 609. Draw a line through the citation if it is not in conformance and it is not considered. Include a copy of this form with the next communication to the Applicant.	